

Magnetron sputtered system

$\text{HRr}(45^\circ, 885\text{nm}) > 99.9\% + \text{Rr}(45^\circ, 1064\text{nm}) < 3\%$

fig. 1 reflection,  $45^\circ$

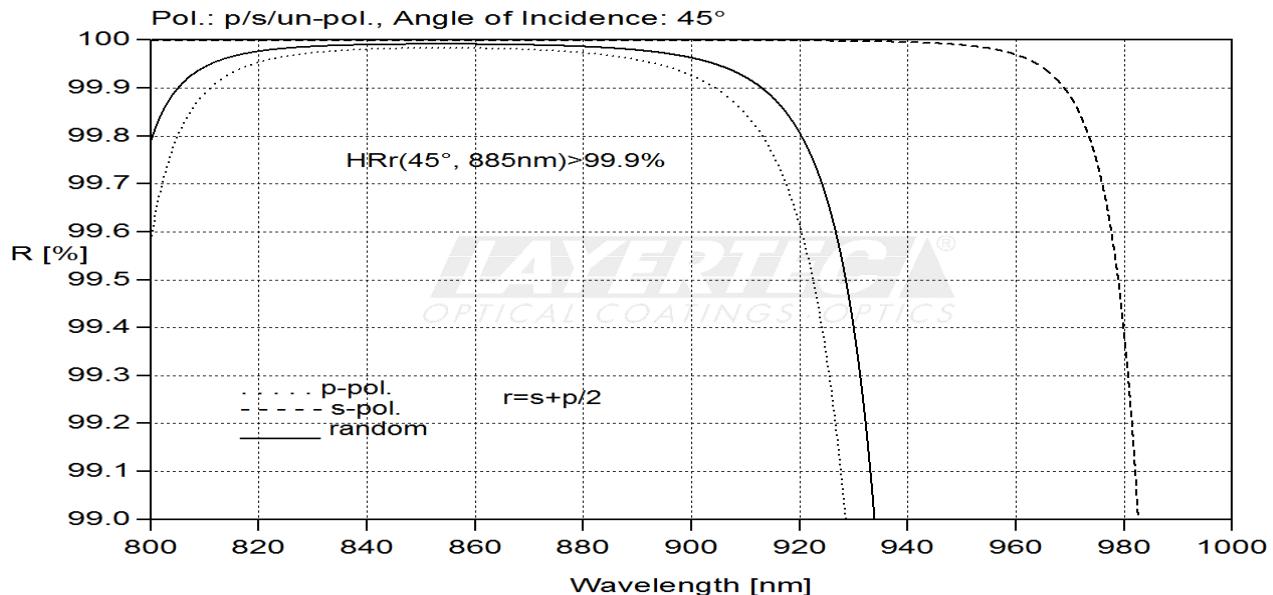


fig. 2 reflection,  $45^\circ$

